

"Phase Transformation in Materials"

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Contents in Phase Transformation

Background to understand phase transformation (Ch1) Thermodynamics and Phase Diagrams

(Ch2) Diffusion: Kinetics

(Ch3) Crystal Interface and Microstructure

(Ch4) Solidification: Liquid \rightarrow Solid

Representative Phase transformation

(Ch5) Diffusional Transformations in Solid: Solid \rightarrow Solid

(Ch6) Diffusionless Transformations: Solid → Solid

Contents for previous class

• **Diffusion** : Movement of atoms to reduce its chemical potential μ . driving force: Reduction of G

Down-hill diffusion movement of atoms from a high C_B region to low C_B region. **Up-hill diffusion** movement of atoms from a low C_B region to high C_B region.

- Interstitial Diffusion / Substitution Diffusion
 - Steady-state diffusion Fick's First Law

$$J_{B} = \frac{1}{6}\Gamma_{B}(n_{1} - n_{2}) = -\left(\frac{1}{6}\Gamma_{B}\alpha^{2}\right)\frac{\partial C_{B}}{\partial x} = -D_{B}\frac{\partial C_{B}}{\partial x}$$

Concentration varies with position. (atoms $m^{-2} s^{-1}$)

- Nonsteady-state diffusion – Fick's Second Law



- For random walk in 3 dimensions, after n steps of length α
- **Effect of Temperature on Diffusivity**

$$r = \alpha \sqrt{(\Gamma t)} = f(D) = 2.4\sqrt{Dt}$$
$$\log D = \log D_0 - \frac{Q}{2.3R} \left(\frac{1}{T}\right) \qquad 3$$

Contents for today's class

Interstitial Diffusion / Substitutional Diffusion

2.

3.

- Steady-state diffusion- Fick's First Law
- Concentration varies with position.
- Non-steady-state diffusion: Fick's Second Law
- Concentration varies with time and position.
 - Atomic Mobility
 - Tracer Diffusion in Binary Alloys
 - High-Diffusivity Paths
 - 1. Diffusion along Grain Boundaries and Free Surface
 - 2. Diffusion Along Dislocation
 - Diffusion in Multiphase Binary Systems

- 1. Self diffusion in pure material
 - Vacancy diffusion
 - Diffusion in substitutional alloys

Q. How to solve the diffusion equations? : Application of Fick's 2nd law

homogenization, carburization, decarburization, diffusion across a couple

Solutions to the diffusion equations (Application of Fick's 2nd law)

Ex1. Homogenization

of sinusoidal varying composition

in the elimination of segregation in casting



Fig. 2.10 The effect of diffusion on a sinusoidal variation of composition.

C: the mean composition l: half wavelength

 β_0 : the amplitude of the initial concentration profile

 $\frac{\partial C_B}{\partial t} = D_B \frac{\partial^2 C_B}{\partial \mathbf{x}^2}$

Rigorous solution of

$$\frac{\partial C}{\partial t} = D \frac{\partial^2 C}{\partial x^2}$$

Using a method of variable separation

Let C = XT

$$X \frac{dT}{dt} = DT \frac{d^2 X}{dx^2}$$
$$\frac{1}{DT} \frac{dT}{dt} = \frac{1}{X} \frac{d^2 X}{dx^2} = -\lambda^2$$

$$\frac{1}{T}\frac{dT}{dt} = -\lambda^2 D$$
$$\frac{d^2 X}{dx^2} + \lambda^2 X = 0$$
$$\frac{d\ln T}{dt} = -\lambda^2 D$$
$$X = A' \cos \lambda x + B' \sin \lambda x$$
$$T = T_0 e^{-\lambda^2 D t}$$
$$X(x,0) \equiv \overline{C} + \beta_0 \sin \frac{\pi x}{l}$$

......

for
$$C(x,0) = \overline{C} + \beta_0 \sin \frac{\pi x}{l}$$

 $\therefore C = (A \cos \lambda x + B \sin \lambda x)e^{-\lambda^2 D t}$
 $\therefore C = A_0 + \sum_{n=1}^{\infty} (A_n \sin \lambda_n x + B_n \cos \lambda_n x)$
 $t = 0 \rightarrow C \equiv \overline{C} + \beta_0 \sin \frac{\pi x}{l} \qquad \lambda = \frac{\pi}{l}$
 $; A_0 = \overline{C}, B_n = 0, A_1 = \beta_0$
 $(A_n = 0 \text{ for all others})$
 $\therefore C \equiv \overline{C} + \beta_0 \sin \frac{\pi x}{l} e^{-\frac{l^2}{2}\pi^2 D}$
 $C = \overline{C} + \beta_0 \sin \frac{\pi x}{l} \exp(-\frac{t}{2})$
 $\tau = \frac{l^2}{\pi^2 D} \quad \tau : \text{ relaxation time}$
 $\beta = \beta_0 \exp(-t/\tau) \quad at \quad x = \frac{l}{2}$

Solutions to the diffusion equations

Ex1. Homogenization of sinusoidal varying composition in the elimination of segregation in casting



decide homogenization rate

The initial concentration profile will not usually be sinusoidal, but in general any concentration profile can be considered as <u>the sum of an infinite series of sine waves of</u> <u>varying wavelength and amplitude</u>, and each wave decays at a rate determined by gits own " τ ". Thus, the short wavelength terms die away very rapidly and <u>the homogenization</u> <u>will ultimately be determined by τ for the longest wavelength component</u>.

Solutions to the diffusion equations

Ex2. Carburization of Steel

The aim of carburization is to increase the carbon concentration in the surface layers of a steel product in order to achiever a harder wear-resistant surface.

- 1. Holding the steel in CH₄ and/or Co at an austenitic temperature.
- 2. By controlling gases the concentration of C at the surface of the steel can be maintained at a suitable constant value.
- 3. At the same time carbon continually diffuses from the surface into the steel.



Carburizing of steel

that is



Fig. 2.11 Concentration profiles at successive times $(t_3>t_2>t_1)$ for diffusion into a semi-infinite bar when the surface concentration Cs is maintained constant.



• Since erf(0.5)~0.5, the depth at which the carbon concentration is midway between C_s and C₀ is given $(x/2\sqrt{Dt}) \cong 0.5$

 $x \cong \sqrt{Dt} \longrightarrow \text{Depth of Carburization}$

Error function

In mathematics, the error function (also called the <u>Gauss error</u> <u>function</u>) is a non-elementary function which occurs in probability, statistics and partial differential equations.

It is defined as:

$$\mathrm{erf}(x)=\frac{2}{\sqrt{\pi}}\int_{\mathbf{0}}^{x}e^{-t^{2}}dt.$$

By expanding the right-hand side in a Taylor series and integrating, one can express it in the form

$$\operatorname{erf}(x) = \frac{2}{\sqrt{\pi}} \sum_{n=0}^{\infty} \frac{(-1)^n x^{2n+1}}{(2n+1)n!} = \frac{2}{\sqrt{\pi}} \left(x - \frac{x^3}{3} + \frac{x^5}{10} - \frac{x^7}{42} + \frac{x^9}{216} - \cdots \right)$$

for every real number x. (From Wikipedia, the free encyclopedia)

Error function

 $\operatorname{erf}(z) = \frac{2}{\sqrt{\pi}} \int_{0}^{z} \exp(-y^{2}) dy$

Table 1-1. The Error Function



(a) Schematic diagram illustrating the main features of the error function.

| erf(z) 0.7707 0.7969 0.8209 0.8427 | |
|--|--|
| 0.7707 0.7969 0.8209 0.8427 | |
| 0.7969 0.8209 0.8427 | |
| 0.8209 | |
| 0.8427 | |
| 0 0000 | |
| 0.8802 | |
| 0.9103 | |
| 0.9340 | |
| 0.9523 | |
| 0.9661 | |
| 0.9763 | |
| 0.9838 | |
| 0.9891 | |
| 0.9928 | |
| 0.9953 | |
| 0.9981 | |
| 0.9993 | |
| 0.9998 | |
| 0.9999 | |
| | 0.8802 0.9103 0.9340 0.9523 0.9661 0.9763 0.9838 0.9891 0.9928 0.9953 0.9981 0.9993 0.9998 0.9999 |

Carburizing of steel

Depth of Carburization?

- 1) Specimen ~ infinitely long.
- 2) Diffusion coefficient of carbon in austenite increases with increasing concentration, but an approximate solution: Taking an average value

The error function solution:







Fig. 2.11 Concentration profiles at successive times $(t_3>t_2>t_1)$ for diffusion into a semi-infinite bar when the surface concentration Cs is maintained constant.

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$$\frac{C_{\rm s}-C}{C_{\rm s}-C_{\rm 0}}= erf\left(\frac{x}{2\sqrt{Dt}}\right) \qquad \text{erf(0.5)}\approx 0.5 \qquad C=\frac{C_{\rm s}+C_{\rm 0}}{2}$$

• Since $erf(0.5)\approx 0.5$, the depth at which the carbon concentration is <u>midway between C_s and C_0 is given $(x/2\sqrt{Dt}) \cong 0.5$ </u> that is $x \cong \sqrt{Dt} \rightarrow Depth of Carburization}$

Carburizing of steel

Thus the thickness of the carburized layer is $\cong \sqrt{Dt}$.

Note also that the depth of any is concentration line is directly proportion to \sqrt{Dt} , i.e. to obtain a twofold increase in penetration requires a fourfold increase in time.

(2배의 침투 깊이 → 4배의 시간)



 $C_s =$ Surface concentration $C_0 =$ Initial bulk concentration



Solutions to the diffusion equations

Ex4. Diffusion Couple

Joining of two semi-infinite specimens of compositions C_1 and C_2 ($C_1 > C_2$)



Fig. 2.12 (b) concentration profiles at successive times (t2>t1>0) when two semi-infinite bars of different composition are annealed after welding.

The section is completed with **4 example solutions to Fick's 2nd law:** *carburisation, decarburisation, diffusion across a couple* and *homogenisation*.

The solutions given are as follows:

| Process | Solution | | |
|------------------|---|--|--|
| Homogenization | $C = C_{\text{mean}} + \beta_0 \sin\left(\frac{\pi x}{l}\right) \exp\left(-\frac{t}{\tau}\right)$ | | |
| | C_{mean} = Mean concentration b_0 = Initial concentration amplitude l = half-wavelength of cells t = relaxation time | | |
| Carburization | $C = C_{\rm S} - (C_{\rm S} - C_0) \operatorname{erf}\left(\frac{x}{2\sqrt{Dt}}\right)$ | | |
| | $C_s = Surface$ concentration $C_0 = Initial$ bulk concentration | | |
| Decarburization | $C = C_0 \operatorname{erf}\left(\frac{x}{2\sqrt{Dt}}\right)$ C ₀ = Initial bulk concentration | | |
| Diffusion Couple | $C = \left(\frac{C_1 + C_2}{2}\right) - \left(\frac{C_1 - C_2}{2}\right) \operatorname{erf}\left(\frac{x}{2\sqrt{Dt}}\right)$ | | |
| | C_1 = Concentration of steel 1 C_2 = Concentration of steel 2 | | |

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Q. Interstitial diffusion vs Substitutional diffusion

- 1. Self diffusion in pure material
- 2. Vacancy diffusion
- 3. Diffusion in substitutional alloys

Interstitial Diffusion / Substitutional Diffusion

- Diffusion in dilute interstitial alloys ~ relatively simple

because the diffusing atoms are <u>always surrounded by vacant sites</u> to which they can jump whenever they have enough to overcome the energy barrier for migration.

- In substitutional diffusion,

An atom can only jump if there happens to be vacant site at one of the adjacent lattice positions

Probability of vacancy x probability of jump

→ amenable to a simple atomic model: self-diffusion (순금속의 자기확산)

most likely to occur back

into the same vacancy

1. Self diffusion in pure material

The rate of self-diffusion can be measured experimentally by introducing a few radioactive A atoms (A*) into pure A and measuring the rate at which penetration occurs at various temperatures. Since A* and A atoms are chemically identical their jump frequencies are almost identical.

Atoms

 $D_{A}^{*} = f D_{A}$ (f: correlation factor) close to unity

Assumption : unrelated to the previous jump

 $D_A^* = D_A = \frac{1}{6}\Gamma_A \alpha^2$

Diffusion coefficient

The next jump is not equally probable in all directions.

Q. Interstitial diffusion vs Substitutional diffusion

- 1. Self diffusion in pure material
- 2. Vacancy diffusion
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Substitutional diffusion

1. Self diffusion in pure material

Probability of vacancy x probability of jump

What would be the jump frequency in substitutional diffusion?

Atoms

 $\rightarrow \exp(-\Delta G_m/kT)$

 $\rightarrow zX_{v}$

An atom next to a vacancy can make a jump provided

it has enough thermal energy to overcome ΔG_m .

The probability that an adjacent site is vacant



$$D_{A} = \frac{1}{6} \alpha^{2} zv \exp \frac{-(\Delta G_{m} + \Delta G_{v})}{RT} \qquad \Delta G = \Delta H - T\Delta S$$

$$D_{A} = \frac{1}{6} \alpha^{2} zv \exp \frac{\Delta S_{m} + \Delta S_{v}}{R} \exp(-\frac{\Delta H_{m} + \Delta H_{v}}{RT})$$
Z=number of nearest neighbors/ v= temperature independent frequency
For most metals: v ~ 10¹³, fcc metals : z = 12, $\alpha = a/\sqrt{2}$

$$D_{A} = D_{0} \exp(-\frac{Q_{SD}}{RT}) \qquad D_{0} = \frac{1}{6} \alpha^{2} zv \exp \frac{\Delta S_{m} + \Delta S_{v}}{R}$$

$$Q_{SD} = \Delta H_{m} + \Delta H_{v}$$
: self-diffusion requires the presence of vacancies

~Same with interstitial diffusion except that the activation energy for self-diffusion has an extra term

* interstitial diffusion

Thermally activated process jump frequency Γ_B ?

$$\Gamma_{B} = Z \nu \exp(-\Delta G_{m} / RT)$$

- Z : nearest neighbor sites
- v : vibration frequency

 $\Delta \boldsymbol{G}_m$: activation energy for moving



Temperature Dependence of Diffusion



How to determine Q_{ID} experimentally?

$$\log D = \log D_0 - \frac{Q}{2.3R} \left(\frac{1}{T}\right)$$

Therefore, from the slope of the D-curve in an log D vs 1/T coordinate, the activation energy may be found.

Experimental Determination of D

 Deposit a known quantity (M) of a radioactive isotope A*



Fig. 2.14 Illustration of the principle of tracer diffusion and of the planar source method for determining the self-diffusion coefficient of gold. (a) Initial diffusion couple with planar source of radioactive gold Au^{*}. (b) Distribution of Au^{*} after diffusion for 100h at 920 $^{\circ}$ C

(2.18)

Table 2.2 Experimental Data for Substitutional Self-Diffusionin Pure Metals at Atmospheric Pressure

| | | • | | | | | For a given structure and head type |
|----------------------------|-------------------|--------------------|--|------------------------------|--------------------|---|---|
| Class | Metal | T _m (K) | D ₀ (mm ² s ⁻¹) | Q (kJ mol ⁻¹) | $\frac{Q}{RT_{m}}$ | $Q(T_{\rm m})$ (μ m ² s ⁻¹) | O/D T is result to see a fact to |
| bcc (rare earths) | ε-Pu | 914 | 0.3 | 65.7 | 8.7 | 53 | Q/R I _m is roughly constant; |
| | δ-Ce | 1071 | 1.2 | 90.0 | 10.1 | 49 | \rightarrow \bigcirc is near the near entire of the T |
| •••••• | γ-La | 1193 | 1.3 | 102.6 | 10.4 | 42 | \Box Q is roughly proportional to $I_{\rm m}$. |
| | γ-Yb | 1796 | 1.2 | 121.0 | 8.1 | 3600 | |
| bcc (alkali metals) | Rb | 312 | 23 | 39.4 | 15.2 | 5.8 | |
| | K | 337 | 31 | 40.8 | 14.6 | 15 | |
| | Na | 371 | 24.2 | 43.8 | 14.2 | 16 | Within each class, $D(I_m)$ and D_0 |
| | Li | 454 | 23 | 55.3 | 14.7 | 9.9 | are energy metally constants |
| bcc (transition metals) | β-T1 | 577 | 40 | 94.6 | 19.7 | 0.11 | are approximately constants. |
| | Eu | 1095 | 100 | 143.5 | 15.8 | 14 | Most close-packed metals |
| | Er | 1795 | 451 | 302.4 | 20.3 | 0.71 | ex) for fcc and hcp $\Omega/RT \sim 18$ and |
| | α-Fe ^a | 1811 | 200 | 239.7 | 15.9 | 26 | ory for foo and hop, writing to and |
| | δ-Fe ^a | 1811 | 190 | 238.5 | 15.8 | 26 | $D(T_m) \sim 1 \ \mu m^2 s^{-1} (10^{-12} \ m^2 s^{-1})$ |
| | β–Ti | 1933 | 109 | 251.2 | 15.6 | 18 | |
| | β-Ζρ | 2125 | 134 | 273.5 | 15.5 | 25 | |
| | Cr | 2130 | 20 | 308.6 | 17.4 | 0.54 | $\log D_0$ |
| | v | 2163 | 28.8 | 309.2 | 17.2 | 0.97 | |
| | Nb | 2741 | 1240 | 439.6 | 19.3 | 5.2 | $\frac{-Q}{-Q}$ |
| | Mo | 2890 | 180 | 460.6 | 19.2 | 0.84 | $30pe = \frac{1}{2.3R}$ |
| | Та | 3269 | 124 | 413.3 | 15.2 | 31 | log D |
| | w | 3683 | 4280 | 641.0 | 20.9 | 3.4 | |
| hcp ^a | Cd | 594 | ∥c5 | 76.2 | 15.4 | 0.99 | |
| | _ | | $\perp c 10$ | 79.9 | 16.2 | 0.94 | |
| | Zn | 692 | c 13 | 91.6 | 15.9 | 1.6 | |
| | | | ⊥c18 | 96.2 | 16.7 | 0.98 | 1/T |
| | Mg | 922 | c 100 | 134.7 | 17.6 | 2.3 | For a given structure and head type |
| | | (01 | ⊥ c 150 | 136.0 | 17.8 | 2.9 | For a given structure and bond type, |
| tcc | Pb | 601 | 137 | 109.1 | 21.8 | 0.045 | |
| | AI | 933 | 170 | 142.0 | 18.3 | 1.9 | $\nu_{(1/1_m)} \sim \text{constant}$ |
| | Ag | 1234 | 40 | 184.6 | 18.0 | 0.61 | |
| | Au | 1336 | 10.7 | 176.9 | 15.9 | 1.3 | T/T : homologous tomporaturo |
| | Ni | 1356 | 190 | 200.3 | 17.8 19.5 | 0.59 | 25 |

* Melting point diffusivities for various classes of materials:

: The diffusion coefficients of all materials with a given crystal structure and bond type will be approximately the same at the same fraction of their melting temperature, i.e. $D(T/T_m) = \text{const.}$



For a given structure and bond type, Q/RT_m is roughly constant;



$$\frac{L}{RT_E} = \ln \frac{A_M}{A_F}$$

b) $A_M \sim 1$ for all liquid, A_F depends on crystal structure

- **Metallic structure** (FCC, C.P.H, and BCC, "less localized bonding") ~ good relationship compared with the structures which are covalently bonded ("specific directional bonds").

- Molecular liquid such as F_2 , $Cl_2 \sim extra \ condition \ for <math>A_F$
- (•.• molecule must be correctly oriented in order to be accommodated.)



Consider the effect of temperature on self-diffusion in Cu:

ex) At 800°C, D_{Cu} = 5 × 10⁻⁹ mm²s⁻¹, α = 0.25 nm Γ_{Cu} : ?

$$D_{B} = \frac{1}{6} \Gamma_{B} \alpha^{2} \qquad \Gamma_{Cu} = 5 \times 10^{5} \text{ jumps s}^{-1}$$



 \rightarrow Each atom would make one jump every 10¹² years!

Q. Interstitial diffusion vs Substitutional diffusion

- 1. Self diffusion in pure material
- 2. Vacancy diffusion
- 3. Diffusion in substitutional alloys

2. Vacancy diffusion

All the surrounding atoms are possible jump sites of a vacancy, which is analogous to interstitial diffusion.





Vacancies

Comparing D_v with the self-diffusion coefficient of A, D_A ,

$$D_{v} = D_{A} / X_{v}^{e}$$

This shows in fact that the diffusivity of vacancy (D_v) is many orders of magnitude greater than the diffusivity of substitutional atoms (D_A).

3. Diffusion in substitutional alloys

* During self-diffusion, all atoms are chemically identical. : probability of finding a vacancy and jumping into the vacancy ~ equal

* In binary substitutional alloys, each atomic species must be given its own intrinsic diffusion coefficient D_A or D_B .





